

# Synthesis of $\text{Si}_3\text{N}_4$ powder with a controllable alpha/beta ratio by sol-gel assisted carbothermal reduction and nitridation

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## ABSTRACT

The controllable  $\alpha/\beta$  ratio of  $\text{Si}_3\text{N}_4$  powder was synthesized using tetraethyl orthosilicate (TEOS), glucose,  $\text{MgCl}_2$  and  $\text{YCl}_3 \cdot 6\text{H}_2\text{O}$  by sol-gel assisted carbothermal reduction and nitridation (CRN). This study aimed to investigate the impact of various parameters, including a  $\text{H}_2\text{O}/\text{TEOS}$  mol ratio of the sol, a C/Si mol ratio, sintering aids, and the temperature of CRN on the phase transformation of  $\alpha\text{-Si}_3\text{N}_4$ . The results demonstrated that the  $\text{H}_2\text{O}/\text{TEOS}$  ratio significantly influenced the relative content of  $\alpha$  and  $\beta$  phase in  $\text{Si}_3\text{N}_4$  by changing the morphological characteristics of  $\text{SiO}_2$ . When the  $\text{H}_2\text{O}/\text{TEOS}$  ratio was 100,  $\beta\text{-Si}_3\text{N}_4$  powder with an approximate  $\beta$  content over 88 wt% was synthesized at 1500 °C. This remarkable phase transformation was likely facilitated by the eutectic liquid phase consisting of  $\text{MgSiO}_3/\text{Mg}_2\text{SiO}_4$ . The SEM image revealed rod-like whiskers with a length around 1.4  $\mu\text{m}$  for the  $\beta\text{-Si}_3\text{N}_4$  grains. Due to the presence of liquid phase, the synthesis of spherical-like  $\alpha\text{-Si}_3\text{N}_4$  nanopowder with an  $\alpha$ -phase content of 91 wt% was achieved at a lower temperature of 1450 °C, with an  $\text{H}_2\text{O}/\text{TEOS}$  ratio of 15 and a C/Si ratio of 4. The size of the particles was about 70 nm due to the reduced reaction temperature. Furthermore, without the addition of any sintering aids or  $\text{Si}_3\text{N}_4$  seeds, high purity  $\alpha\text{-Si}_3\text{N}_4$  with an  $\alpha$  phase content approaching 96 wt% could be synthesized at 1500 °C, using an  $\text{H}_2\text{O}/\text{TEOS}$  ratio of 15 and a C/Si ratio of 4. The resulting  $\alpha\text{-Si}_3\text{N}_4$  powder exhibited an extremely regular hexagonal prism shape with a length of approximately 2  $\mu\text{m}$ .

## 1. Introduction

$\text{Si}_3\text{N}_4$  ceramic is expected to become the next-generation substrate for high-power devices due to its high thermal conductivity, strength, excellent thermal shock resistance, and low dielectric constant [1–6]. In order to achieve high-performance  $\text{Si}_3\text{N}_4$  ceramic, it is crucial to prepare high-quality  $\text{Si}_3\text{N}_4$  powder. The particle size, phase content, and particle morphology greatly influence the ceramic properties [7]. Consequently, the study of  $\text{Si}_3\text{N}_4$  powder has always received significant attention from researchers. In general, there are two common crystalline forms of  $\text{Si}_3\text{N}_4$ :  $\alpha\text{-Si}_3\text{N}_4$  and  $\beta\text{-Si}_3\text{N}_4$  [8]. While both belong to the hexagonal system, they differ in the length of the direction along the C-axis, which is caused by the stacking of atoms, resulting the difference of their property [9]. Additionally, under high-temperature and liquid phase conditions,  $\alpha\text{-Si}_3\text{N}_4$  spontaneously transforms to  $\beta\text{-Si}_3\text{N}_4$  due to its unstable lattice structure [10]. Therefore,  $\alpha\text{-Si}_3\text{N}_4$  and  $\beta\text{-Si}_3\text{N}_4$  have different preparation and application. The preparation of  $\alpha\text{-Si}_3\text{N}_4$  powder have various synthesis methods, such as nitridation of silicon, silicon-imide decomposition, and CRN [11–13]. High purity  $\alpha\text{-Si}_3\text{N}_4$  is

usually used as the raw material of  $\text{Si}_3\text{N}_4$  ceramic since it significantly improves the densification of ceramic during the sintering process [14]. The preparation of  $\beta\text{-Si}_3\text{N}_4$  have been using  $\alpha\text{-Si}_3\text{N}_4$  as a raw material,  $\text{Y}_2\text{O}_3$ ,  $\text{MgO}$ , or other oxides as sintering aids to promote the phase transformation from  $\alpha\text{-Si}_3\text{N}_4$  to  $\beta\text{-Si}_3\text{N}_4$  at temperatures usually above 1700 °C [12,15]. This  $\beta\text{-Si}_3\text{N}_4$  powder is typically applied as a filling material for high polymer materials to enhance their thermal conductivity [16,17]. Furthermore, by adjusting the  $\alpha/\beta$  phase ratio of  $\text{Si}_3\text{N}_4$ , the advantages of both  $\alpha\text{-Si}_3\text{N}_4$  and  $\beta\text{-Si}_3\text{N}_4$  can be combined, resulting in  $\text{Si}_3\text{N}_4$  ceramic with unique properties achieved through changes in the microstructure [18]. For instance, Xing et al. [19] enhanced the mechanical properties of  $\text{Si}_3\text{N}_4$  ceramic by in-situ growth of  $\beta\text{-Si}_3\text{N}_4$  whiskers in  $\text{Si}_3\text{N}_4$  powder. Yeh et al. [20] also found that substituting high-purity  $\alpha$  or  $\beta\text{-Si}_3\text{N}_4$  powder with  $(\alpha+\beta)\text{-Si}_3\text{N}_4$  significantly decreased the synthesis temperature of Sialon composite material. Therefore,  $\alpha\text{-Si}_3\text{N}_4$ ,  $\beta\text{-Si}_3\text{N}_4$ , and  $(\alpha+\beta)\text{-Si}_3\text{N}_4$  all have their own potential applications. However, to the best of our knowledge, there are few studies that focus on the preparation and influential factors of the phase transformation of  $\text{Si}_3\text{N}_4$  powder. Moreover, there is a lack of a universal

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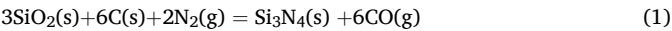
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method capable of synthesizing not only the controllable  $\alpha/\beta$  phase content of  $\text{Si}_3\text{N}_4$  powder, but also high-purity  $\alpha\text{-Si}_3\text{N}_4$  and  $\beta\text{-Si}_3\text{N}_4$  powder.

The CRN method offers significant advantages for potential industrial production of  $\text{Si}_3\text{N}_4$  powder due to its cost-effectiveness and stability compared to other processes [21]. This technique utilizes  $\text{SiO}_2$  and C as raw materials to synthesize  $\text{Si}_3\text{N}_4$  powder under high temperatures and a flowing  $\text{N}_2$  atmosphere, with the overall reaction equation outlined in Equation (1) [22,23].



However, a key limitation of the traditional CRN method lies in the extensive milling time required to achieve a uniform mixing state of the raw materials prior to high-temperature reaction [24]. This poses a challenge for efficient production. Sol-gel is a method commonly used to synthesize high-dispersity powder due to its ability to achieve homogeneous powder mixing and reduce the reaction temperature [25]. Therefore, combining the sol-gel and CRN methods offers a more efficient approach for  $\text{Si}_3\text{N}_4$  powder production. Researchers in this field have made notable progress. For instance, Tan et al. [26] employed TEOS as silicon-source and glucose as carbon-source to synthesize precursor powder through sol-gel method. They postulated that the sol-gel approach significantly enhances the homogeneity of the raw materials compared to traditional mechanical mixing methods, thereby reducing the synthesis temperature required for  $\text{Si}_3\text{N}_4$  powder. Their study demonstrated the synthesis of  $\alpha\text{-Si}_3\text{N}_4$  with a fibrous morphology at 1400 °C. Similarly, Zahra Omid et al. [27] reported the synthesis of  $\text{Si}_3\text{N}_4$  powder with spherical and fibrous morphologies using TEOS and saccharose as raw materials through the sol-gel method. They further investigated the impact of the C/Si ratio and reaction temperature on the growth of  $\text{Si}_3\text{N}_4$  powder. Nonetheless, research on the synthesis of  $\text{Si}_3\text{N}_4$  powder using TEOS and soluble carbon sources remains limited. And in the present research, both  $\alpha\text{-Si}_3\text{N}_4$  and  $\beta\text{-Si}_3\text{N}_4$  coexist, but there is little research focusing on the phase transformation of the  $\text{Si}_3\text{N}_4$  powder [26, 28].

In this study, TEOS and glucose were used as the Si-source and C-source, respectively.  $\text{MgCl}_2$  and  $\text{YCl}_3 \cdot 6\text{H}_2\text{O}$  were used as sintering aids. The sol-gel and CRN processes were combined to synthesize  $\text{Si}_3\text{N}_4$  powder with a controllable  $\alpha/\beta$  ratio. The influence of the  $\text{H}_2\text{O}/\text{TEOS}$  mol ratio of the sol, the C/Si mol ratio, the temperature of CRN, and sintering aids on the phase transformation of  $\text{Si}_3\text{N}_4$  were studied. Furthermore, the microstructure of  $\text{Si}_3\text{N}_4$  powder and growth mechanism of  $\beta\text{-Si}_3\text{N}_4$  were both investigated. Consequently, high-purity  $\alpha\text{-Si}_3\text{N}_4$  with different morphology and  $\beta\text{-Si}_3\text{N}_4$  with whiskers structure were synthesized using the same process.

2. Material and methods

The starting materials of this study were all directly purchased from various companies. These materials include: TEOS (Shanghai Ling Feng Chemical Reagent Co., Ltd, Shanghai, China),  $\text{C}_6\text{H}_{12}\text{O}_6 \cdot \text{H}_2\text{O}$  (Shanghai Titan Technology Co., Ltd, Shanghai, China),  $\text{YCl}_3 \cdot 6\text{H}_2\text{O}$  (Shanghai Titan Technology Co., Ltd, Shanghai, China),  $\text{MgCl}_2$  (Shanghai Boer Chemical Reagents Co., Ltd, Shanghai, China), EtOH (Shanghai Boer Chemical Reagents Co., Ltd, Shanghai, China), HCl (Shanghai Ling Feng Chemical Reagent Co., Ltd, Shanghai, China),  $\text{NH}_3 \cdot \text{H}_2\text{O}$  (Shanghai Titan Technology Co., Ltd, Shanghai, China), deionized water. The starting materials were mixed according to Table 1. A lower water content was found to be unfavorable for dissolving glucose, therefore, the lowest R value was set to 15. After the mixing of the starting materials, HCl was added to bring a solution pH of 2. The solution was then placed in a water bath at 40 °C for 1 h to obtain a high dispersion transparent sol. Subsequently,  $\text{NH}_3 \cdot \text{H}_2\text{O}$  was added dropwise to the sol until the pH reached 8. The sol was aged for a 3 h to form a gel. The gel was crushed into pieces and dried in an oven at 80 °C for 8 h to obtain the precursor

**Table 1**  
The starting composition of the raw materials and the label of the synthesized  $\text{Si}_3\text{N}_4$  powder.

Number	R= $\text{H}_2\text{O}/\text{TEOS}$	C/ Si	SSi/Y/ Mgi	T/°C	Time/ h	Label
1	15	3	93/2/5	1500	4	15-1500-4h-3C-YM
2	20					20-1500-4h-3C-YM
3	40					40-1500-4h-3C-YM
4	60					60-1500-4h-3C-YM
5	80					80-1500-4h-3C-YM
6	100					100-1500-4h-3C-YM
7	120					120-1500-4h-3C-YM
8	140					140-1500-4h-3C-YM
9	60	3	93/2/5	600	3	60-600-3h-3C-YM
10	80					80-600-3h-3C-YM
11	100					100-600-3h-3C-YM
12	120					120-600-3h-3C-YM
13	140					140-600-3h-3C-YM
14	100	3	93/2/5	1550	4	100-1550-4h-3C-YM
15				1600		100-1600-4h-3C-YM
16	15	3	93/2/5	1450	4	15-1450-4h-3C-YM
17		4				15-1450-4h-4C-YM
18		5				15-1450-4h-5C-YM
19	15	3	100/0/0	1450	4	15-1450-4h-3C
20		4				15-1450-4h-4C
21	15	3	100/0/0	1500	4	15-1500-4h-3C
22		4				15-1500-4h-4C

powder. The powder was then placed in a furnace, and the heating rate was set to 5 °C/min until it reached the final temperature. The CRN was performed at different reaction temperatures, including 1450 °C, 1500 °C, 1550 °C, and 1600 °C, for 4 h under high purity flowing nitrogen gas (purity 99.999 %) at a pressure of 0.1 Mpa. The gas flow rate was 300 mL/min. Finally, the powder was placed in a muffle furnace at 600 °C for 3 h to remove any excess carbon. The detailed schematic diagram of the process route was shown in Fig. 1.

The obtained  $\text{Si}_3\text{N}_4$  powder was analyzed for its phase composition using an X-ray diffractometer (XRD, Ultima IV, Rigaku Corporation, Japan) with Cu  $\text{K}\alpha_1$  radiation. A step size of 0.02° (2 $\theta$ ) and a scanning rate of 8°/min were used. The (101) and (201) crystal planes of  $\alpha\text{-Si}_3\text{N}_4$  and the (101) and (200) crystal planes of  $\beta\text{-Si}_3\text{N}_4$  were used to represent the different phase content of  $\text{Si}_3\text{N}_4$ . Equations (2) and (3) were used to calculate the  $\beta$  phase content and  $\alpha$  phase content of  $\text{Si}_3\text{N}_4$ , respectively [29]. It was worth noting that this method assumed pure phase  $\text{Si}_3\text{N}_4$  and the phase content was solely used for qualitative representation of the crystal phase ratio, not the actual content of each phase. Additionally, a field-emission scanning electron microscope (FESEM, GeminiSEM 500, Germany) equipped with an energy dispersive spectrometer (EDS) was used to investigate the microstructure, crystal size, and element composition of  $\text{Si}_3\text{N}_4$ . High-resolution transmission electron microscopy (HRTEM, JEM-2100, Japan) was used to observe the microstructure and lattice fringe of  $\text{Si}_3\text{N}_4$ . Dynamic Light Scattering (DLS, Zetasizer Nano series, Britain) was employed to determine the particle size distribution of  $\text{Si}_3\text{N}_4$ .

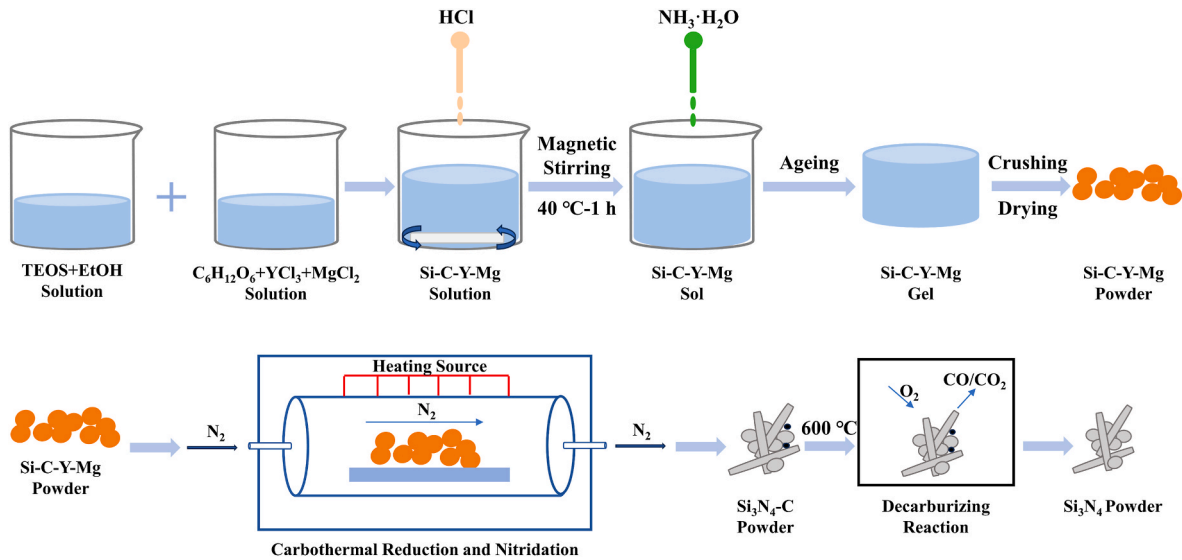


Fig. 1. The schematic diagram of preparation route for  $\text{Si}_3\text{N}_4$  powder.

$$\beta(\text{wt}\%) = \frac{I_{\beta(101)} + I_{\beta(200)}}{I_{\beta(101)} + I_{\beta(200)} + I_{\alpha(101)} + I_{\alpha(201)}} \times 100\% \quad (2)$$

$$\alpha(\text{wt}\%) = 1 - \beta(\text{wt}\%) \quad (3)$$

### 3. Results and discussion

#### 3.1. Influence of the $\text{H}_2\text{O}/\text{TEOS}$ ratio

The samples labeled R-1500-4h-3C-YM ( $R = 15$  to  $140$ ) were used to investigate the influence of different  $\text{H}_2\text{O}/\text{TEOS}$  ratios ( $R$ ) on the synthesis of  $\text{Si}_3\text{N}_4$  powder, and the detailed parameters of the process were shown in Table 1. The XRD patterns of the  $\text{Si}_3\text{N}_4$  powder could be seen from Fig. 2 (a). The main characteristic peaks were matched well with  $\text{Si}_3\text{N}_4$ , indicating the successful synthesis of  $\text{Si}_3\text{N}_4$  powder. In addition, the corresponding crystalline phase of the peaks were marked as  $\alpha$  and  $\beta$ , respectively, based on the position of the characteristic peaks of  $\alpha\text{-Si}_3\text{N}_4$  and  $\beta\text{-Si}_3\text{N}_4$  ( $\alpha\text{-Si}_3\text{N}_4$ , PDF#76–1407;  $\beta\text{-Si}_3\text{N}_4$ , PDF#76–1413). Interestingly, the relative peak intensities of  $\alpha\text{-Si}_3\text{N}_4$  and  $\beta\text{-Si}_3\text{N}_4$  varied significantly with the increase in the  $R$  value. To demonstrate this change more clearly, the  $\beta$  phase content of  $\text{Si}_3\text{N}_4$  was calculated using formula (2), and the detailed calculation process was provided in the supporting information. The results, shown in Fig. 2 (b), revealed that the  $\beta$  phase content of  $\text{Si}_3\text{N}_4$  initially increased and then decreased with

the continuous increase in the  $R$  value. Within the range of  $15\text{--}100$ , the  $\beta$  phase content increased from a minimum of  $14\text{ wt}\%$  to almost  $88\text{ wt}\%$ . However, when the  $R$  value was in the range of  $100\text{--}140$ , the  $\beta$  phase content began to decrease, from a maximum of  $88\text{ wt}\%$  to  $32\text{ wt}\%$ . These findings indicated that the  $\alpha$  and  $\beta$  phase content of  $\text{Si}_3\text{N}_4$  can be controlled to some extent by adjusting the  $\text{H}_2\text{O}/\text{TEOS}$  ratio of the sol.

To comprehensively investigate the factors contributing to the variation in  $\beta$  phase content in  $\text{Si}_3\text{N}_4$  with different  $R$  values, a representative set of precursors spanning  $R$  values from  $60$  to  $140$  was selected for examining the morphological changes of  $\text{SiO}_2$  produced by sol-gel process. Initially, these precursors were subjected to calcination at  $600\text{ }^\circ\text{C}$  for  $3\text{ h}$  to eliminate  $\text{H}_2\text{O}$  and carbon, followed by characterization utilizing XRD and SEM techniques. The results were shown in Fig. 3 and 4. One of the XRD patterns of the precursors was depicted in Fig. 3, where a distinct broad peak at  $2\theta = 23$  indicated that the powder was amorphous  $\text{SiO}_2$  after burning. The SEM images listed in Fig. 4 exhibited varying morphology of  $\text{SiO}_2$  particles with different  $R$  values. It could be observed that as the  $R$  value increased, there was a significant change in the morphology of  $\text{SiO}_2$  particles. Initially, it was evident that the primary particle size of the  $\text{SiO}_2$  prepared via sol-gel process was extremely small, approximately around  $40\text{ nm}$ , as illustrated by Fig. 4 (a), 4 (b) and 4 (c). Furthermore, the high surface energy of  $\text{SiO}_2$  and gelation process resulted in the formation of a porous network structure, which facilitated the reduction reaction between

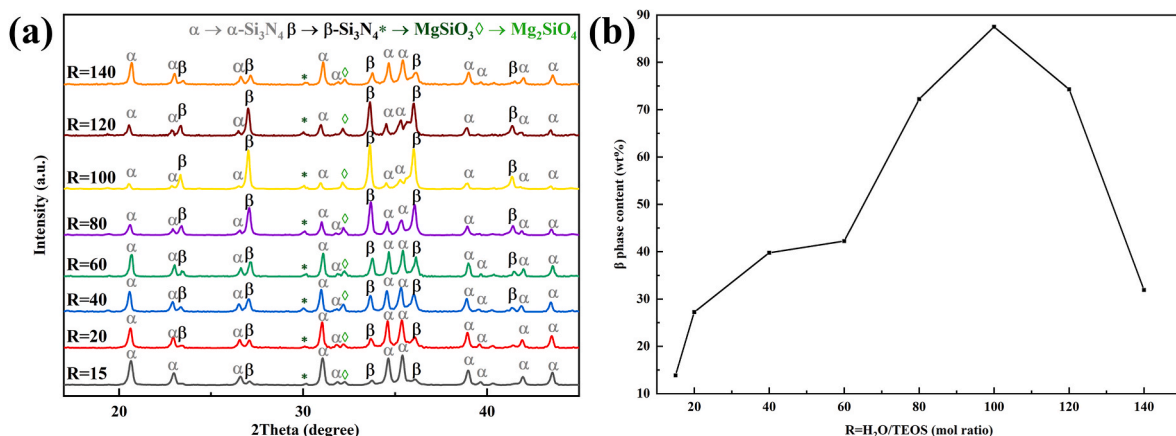


Fig. 2. The (a) XRD patterns and (b) line chart of  $\beta$  content variation with respect to  $R$  of  $\text{Si}_3\text{N}_4$  powder synthesized at  $1500\text{ }^\circ\text{C}$  for  $4\text{ h}$  with varying  $R$  values.

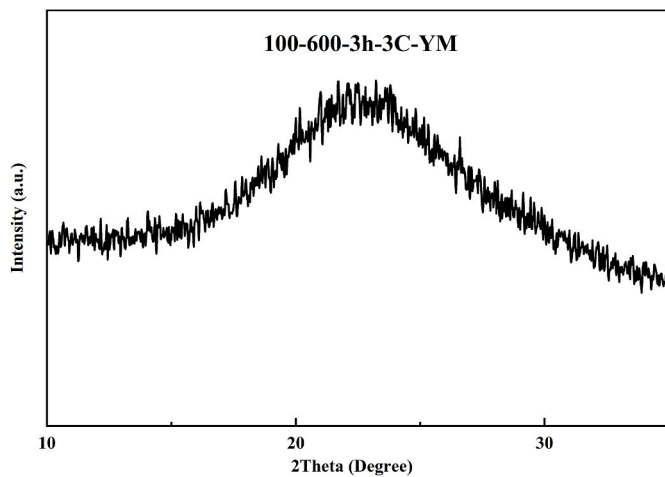
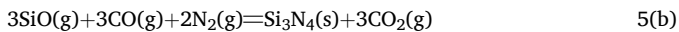
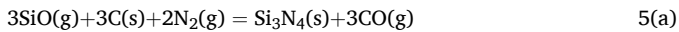
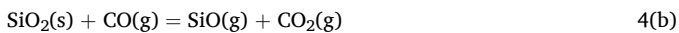
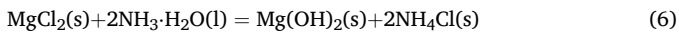


Fig. 3. XRD pattern of precursor with R = 100 at 600 °C for 3 h.

SiO<sub>2</sub> and C (Equation 4 (a) and 4 (b)) while promoting the N<sub>2</sub> flow. Consequently, this structure enhanced the synthesis rate of α-Si<sub>3</sub>N<sub>4</sub> (Equation 5 (a) and 5 (b)) and then accelerated the phase transformation [30].



In addition, the obvious characteristic peaks corresponding to MgSiO<sub>3</sub> and Mg<sub>2</sub>SiO<sub>4</sub> (MgSiO<sub>3</sub>: PDF#35–0610; Mg<sub>2</sub>SiO<sub>4</sub>: PDF#72–0296) were observed in XRD patterns. It is known that MgSiO<sub>3</sub> and Mg<sub>2</sub>SiO<sub>4</sub> are eutectic mixtures of SiO<sub>2</sub> and MgO [26,28]. Henceforth, it could be inferred that MgCl<sub>2</sub> used as sintering aid underwent subsequent reaction processes:



During the CRN process, MgCl<sub>2</sub> underwent a series of precipitation and dehydration reactions, ultimately leading to the formation of MgO, as outlined in Equations (6) and (7). Wang et al. [31] reported that the eutectic temperature of SiO<sub>2</sub> and MgO was about 1280 °C. Consequently, at a temperature of 1500 °C, a eutectic reaction occurred, as described by Equations (8) and (9). This phenomenon was further corroborated by the distinct characteristic peaks of MgSiO<sub>3</sub> and Mg<sub>2</sub>SiO<sub>4</sub> observed in the XRD patterns, as shown in Fig. 2 (a). In the CRN process, the presence of a liquid phase not only accelerated mass transfer rate, but also dissolved α-Si<sub>3</sub>N<sub>4</sub> particles and then promoted the phase transformation from α-Si<sub>3</sub>N<sub>4</sub> to β-Si<sub>3</sub>N<sub>4</sub> [32]. As a result, the low eutectic liquid phase formed by SiO<sub>2</sub> and MgO could accelerate solute transfer rate and wet the small particle α-Si<sub>3</sub>N<sub>4</sub>, which ultimately accelerated significant phase transformation of α-Si<sub>3</sub>N<sub>4</sub> [33]. The mechanism for the formation of α-Si<sub>3</sub>N<sub>4</sub> and the phase transformation from α-Si<sub>3</sub>N<sub>4</sub> to β-Si<sub>3</sub>N<sub>4</sub> with the process was shown in Fig. 5. Therefore, β-Si<sub>3</sub>N<sub>4</sub> powder with β content reached nearly 88 wt% was synthesized at relatively low temperature (1500 °C). However, excessive H<sub>2</sub>O content led to severe agglomeration of SiO<sub>2</sub> particles with block morphology observed in Fig. 4 (d). And the surface density increased with R = 140 from Fig. 4 (e). This was due to an excessive increase in water content that raised crosslinking degree and polymerization degree of gel leading to further agglomeration of SiO<sub>2</sub> [34]. Block-shaped SiO<sub>2</sub> had lower reactivity which was not conducive for gas-phase penetration. Therefore, the synthesis rate and transformation rate of α-Si<sub>3</sub>N<sub>4</sub> were strongly decreased and resulting in significantly reduced β phase content in Si<sub>3</sub>N<sub>4</sub>.

In order to observe the microstructure of Si<sub>3</sub>N<sub>4</sub> powder, samples with R values from 60 to 140 were selected for observation using SEM. As indicated in Fig. 6, distinct spherical-like and rod-like grains were observed. The EDS results of one of the Si<sub>3</sub>N<sub>4</sub> powder were shown in Fig. 7, revealing that the rod-like grains (Fig. 7 (b)) and spherical-like grains (Fig. 7 (c)) consisted mainly of Si, N, with small amounts of C and O. The atomic percentage of Si and N was approximately 40 % and 51 % respectively, closely aligned with the theoretical composition of Si<sub>3</sub>N<sub>4</sub>, thus confirmed that both types of grains were indeed Si<sub>3</sub>N<sub>4</sub>. The rod-like whiskers were typical morphology of β-Si<sub>3</sub>N<sub>4</sub>, therefore, spherical-like grain should be α-Si<sub>3</sub>N<sub>4</sub> [35,36]. The validity of this viewpoint can be corroborated by the lattice spacing measurements of Si<sub>3</sub>N<sub>4</sub> obtained through HRTEM analysis [37]. As evident from Fig. 8 (b), the lattice spacing measured for rod-like Si<sub>3</sub>N<sub>4</sub> was 0.380 nm, which aligns closely with the (110) lattice spacing characteristic of β-Si<sub>3</sub>N<sub>4</sub>. Similarly, Fig. 8 (d) revealed a lattice spacing of 0.259 nm for the

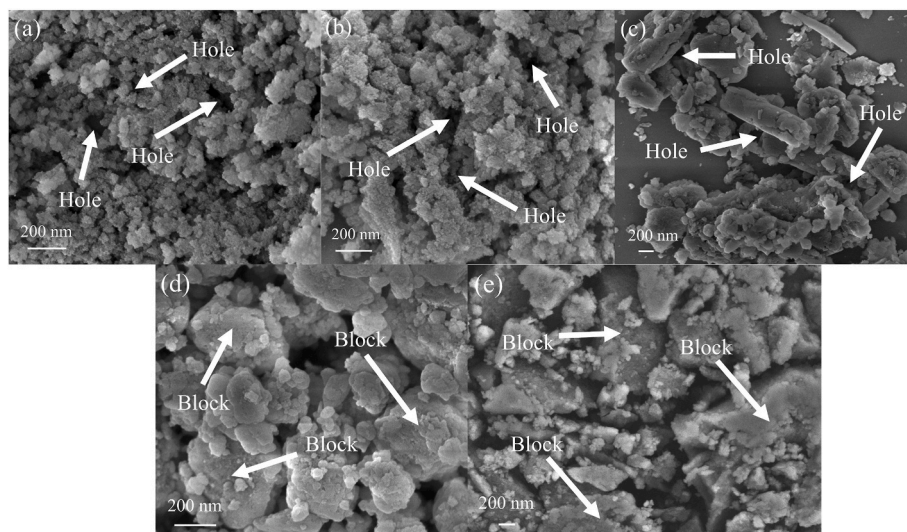


Fig. 4. The SEM images of SiO<sub>2</sub> from calcining of precursor with varying R values: (a) R = 60; (b) R = 80; (c) R = 100; (d) R = 120; (e) R = 140.



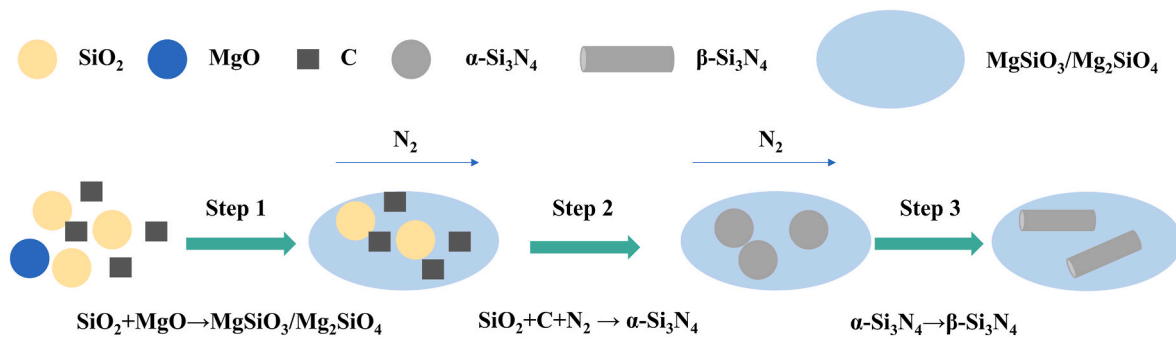


Fig. 5. The schematic diagram of phase transformation mechanism for  $\text{Si}_3\text{N}_4$ .

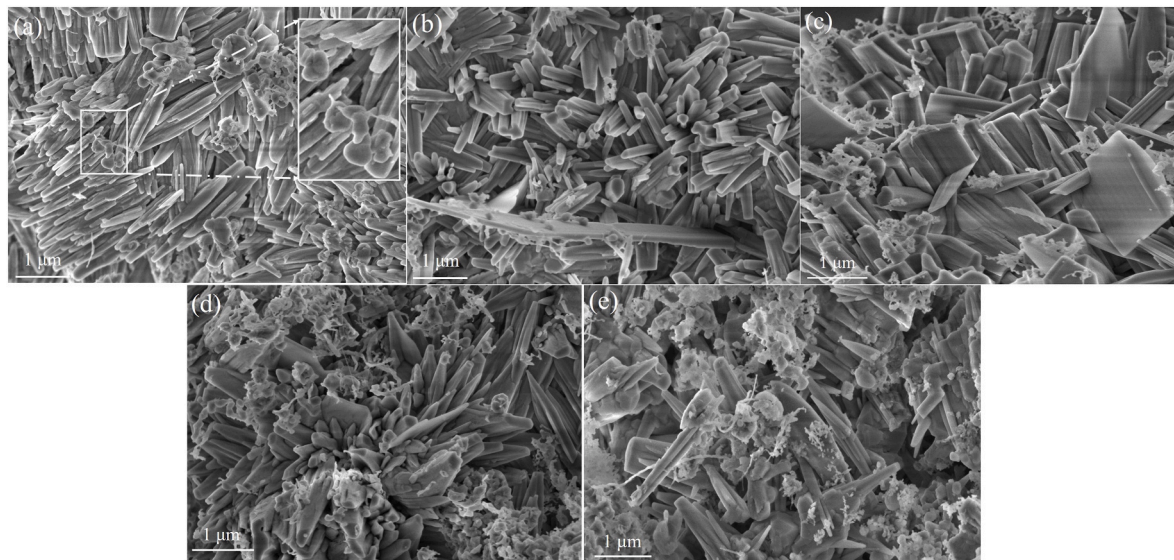


Fig. 6. The SEM images of  $\text{Si}_3\text{N}_4$  powder synthesized with varying R values ((a)  $R = 60$ ; (b)  $R = 80$ ; (c)  $R = 100$ ; (d)  $R = 120$ ; (e)  $R = 140$ ).

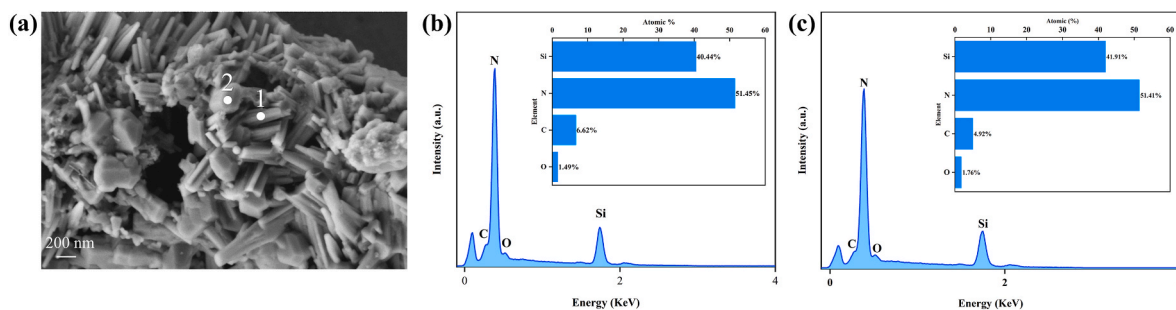


Fig. 7. SEM image (a) and EDS results ((b) the rod-like grain labeled as point 1; (c) the spherical-like grain labeled as point 2) of  $\text{Si}_3\text{N}_4$  powder labeled 80-1500-4h-3C-YM.

spherical-like  $\text{Si}_3\text{N}_4$ , which corresponds well to the (102) lattice spacing of  $\alpha\text{-Si}_3\text{N}_4$ . These observations provided strong support for the proposed viewpoint. Additionally, some irregularly shaped  $\text{Si}_3\text{N}_4$  grains were observed at certain positions within the amplified section of Fig. 6 (a). These grains likely represented  $\text{Si}_3\text{N}_4$  grains that were wet by liquid phase and have undergone incomplete phase transformation. Generally, the phase transformation of  $\text{Si}_3\text{N}_4$  occurs via a dissolution-reprecipitation process. Initially, the  $\alpha\text{-Si}_3\text{N}_4$  grain dissolved in the liquid phase and then reprecipitated as  $\beta\text{-Si}_3\text{N}_4$  through ion migration and grain growth [32]. Therefore, the irregularly shaped  $\text{Si}_3\text{N}_4$  grains supported the presence of low eutectic liquid phase  $\text{MgSiO}_3/\text{Mg}_2\text{SiO}_4$ . Furthermore, as depicted in Fig. 6 (b) and 6 (c), the

grain boundaries of  $\text{Si}_3\text{N}_4$  became shaper with an increase in R value, indicating a gradual improvement in crystallinity with higher water content. Finally, Fig. 6 (d) and 6 (e) demonstrated a gradual increase in spherical-like  $\text{Si}_3\text{N}_4$  grains, indicating a corresponding increase in  $\alpha$  phase content with increasing R value.

The particle size distribution curve of  $\text{Si}_3\text{N}_4$  powder with different R values was shown in Fig. 9. The curve exhibited three distinct peaks corresponding to particle sizes of 300 nm, 1  $\mu\text{m}$ , and 5  $\mu\text{m}$ , matched well with SEM results. The first peak at 300 nm represented spherical-like grains, predominantly composed of  $\alpha\text{-Si}_3\text{N}_4$  (Fig. 6 (a)). The second peak at 1  $\mu\text{m}$  corresponded to rod-like grains, identified as  $\beta\text{-Si}_3\text{N}_4$  (Fig. 6 (b)). The majority of particles fell within this size range. The last

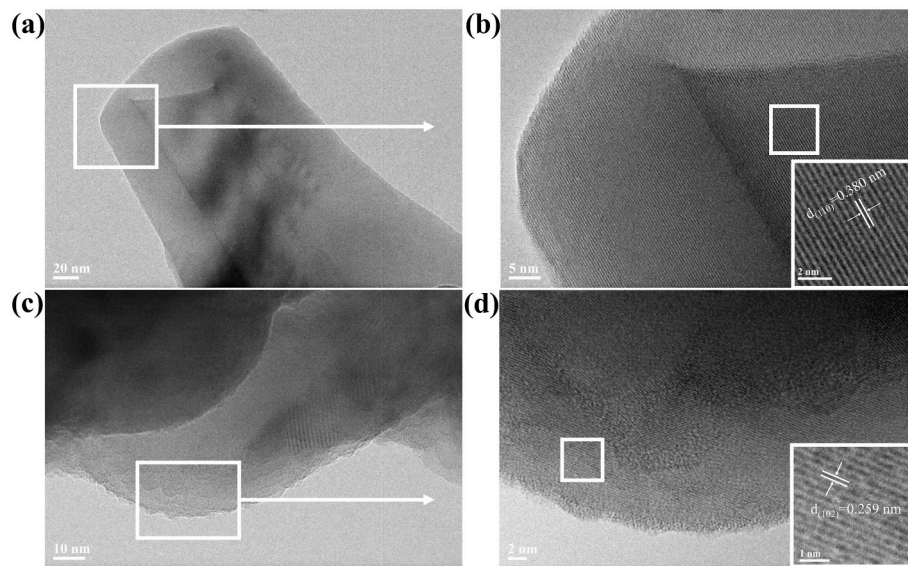


Fig. 8. TEM images of  $\text{Si}_3\text{N}_4$  powder with rod-like whiskers (a, b) and spherical-like grain (c, d).

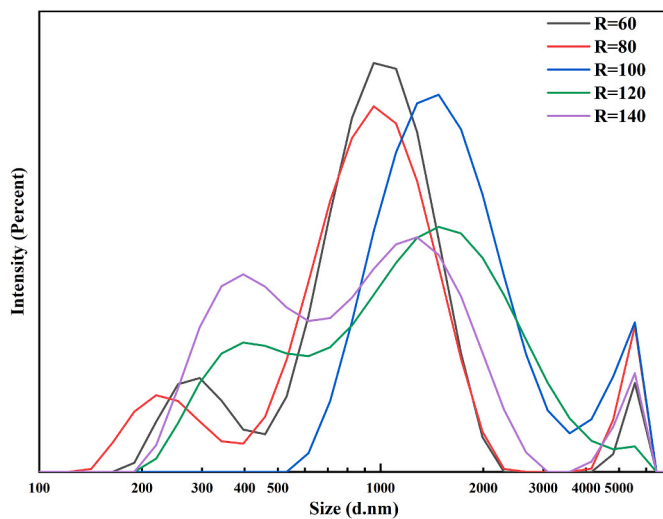


Fig. 9. The particle distribution curve of  $\text{Si}_3\text{N}_4$  powder synthesized with varying R values.

peak corresponded to 5  $\mu\text{m}$  and consisted of grains with abnormal shapes, such as the ribbon-like grain in Fig. 6 (b). In addition, the peak of the particle size distribution curve shifted to the right as the R value increased, indicating an enlargement in the grain size of  $\text{Si}_3\text{N}_4$  with an increase in water content. This trend aligned with the observations from the SEM images. Furthermore, it was worth noting that the intensity of the peak corresponding to small  $\alpha\text{-Si}_3\text{N}_4$  particle sizes exhibited a noticeable trend. As the R value increased from 60 to 80, the intensity gradually decreased. At  $R = 100$ , the peak was almost absent. However, when the R value reached 120 and 140, the peak reappeared, and its intensity gradually magnified. This demonstrated a significant trend of initial decrease followed by subsequent increase, mirroring the variation in  $\alpha$  phase content with R.

### 3.2. Influence of the reaction temperature

The reaction temperature of CRN is a crucial factor that significantly influences the phase transformation of  $\text{Si}_3\text{N}_4$ . In general, an increase in temperature leads to a decrease in the viscosity of liquid and promotes

the phase transformation [38]. Therefore,  $\text{Si}_3\text{N}_4$  powder labeled 100-1500-4h-3C-YM, 100-1550-4h-3C-YM, and 100-1600-4h-3C-YM were selected for investigating the impact of temperature of CRN, and the results were presented in Fig. 10. The line chart illustrating variations in  $\beta$  phase content of  $\text{Si}_3\text{N}_4$  with temperature was shown in Fig. 10 (b). Contrary to expectations, as the temperature increased from 1500  $^{\circ}\text{C}$  to 1550  $^{\circ}\text{C}$ , there was a decrease in  $\beta$  phase content from 88 wt% to 56 wt%. And when temperature reached 1600  $^{\circ}\text{C}$ , there was a slight increase in  $\beta$  phase content to 59 wt%. These findings aligned with previous research by Alcalá et al. [39], who observed a decrease in  $\beta$  phase content of  $\text{Si}_3\text{N}_4$  from 22 wt% to 4 wt% after increasing the temperature by 135  $^{\circ}\text{C}$ . They attributed this phenomenon to difference in partial pressure of CO gas which could inhibit the phase transformation of  $\alpha\text{-Si}_3\text{N}_4$ . Additionally, Fig. 10 (a) showed characteristic peaks corresponding to SiC (SiC, PDF#73-1708), which due to similar reaction temperatures between  $\text{Si}_3\text{N}_4$  and SiC and greater stability of crystal structure exhibited by SiC compared to that of  $\text{Si}_3\text{N}_4$ . As a result, SiC was easily synthesized through Equation (10) when the temperature was high. Consequently, under high temperatures during this study, significant amounts of by-product SiC were synthesized simultaneously generating large quantities of CO gas which ultimately inhibited the phase transformation process within  $\alpha\text{-Si}_3\text{N}_4$ . Therefore, the decrease observed in  $\beta$  phase content with increasing temperature may be due to the formation of by-product SiC at the relative low temperature.



### 3.3. Influence of the C/Si

Weimer et al. [40] reported that  $\alpha\text{-Si}_3\text{N}_4$  has a tendency to synthesize in the presence of a large amount of carbon. Therefore, the influence of the C/Si molar ratio on the phase transformation of  $\text{Si}_3\text{N}_4$  synthesized by sol-gel assisted CRN was investigated. The  $\text{Si}_3\text{N}_4$  powder labeled 15-1450-4h-3C-YM, 15-1450-4h-4C-YM, and 15-1450-4h-5C-YM were studied using XRD and SEM. The XRD patterns were listed in Fig. 11 (a). It showed that all peaks of the synthesized  $\text{Si}_3\text{N}_4$  match well with the standard peak, and the intensity of the  $\alpha\text{-Si}_3\text{N}_4$  peak was stronger than that of the  $\beta\text{-Si}_3\text{N}_4$  peak, indicating the successful synthesis of  $\alpha\text{-Si}_3\text{N}_4$  with high  $\alpha$  phase content. The  $\alpha$  phase content of  $\alpha\text{-Si}_3\text{N}_4$  with different C/Si ratios was shown in Fig. 11 (b). The results revealed an increase from 88 wt% to 91 wt% as C/Si ratio increased from 3 to 4,

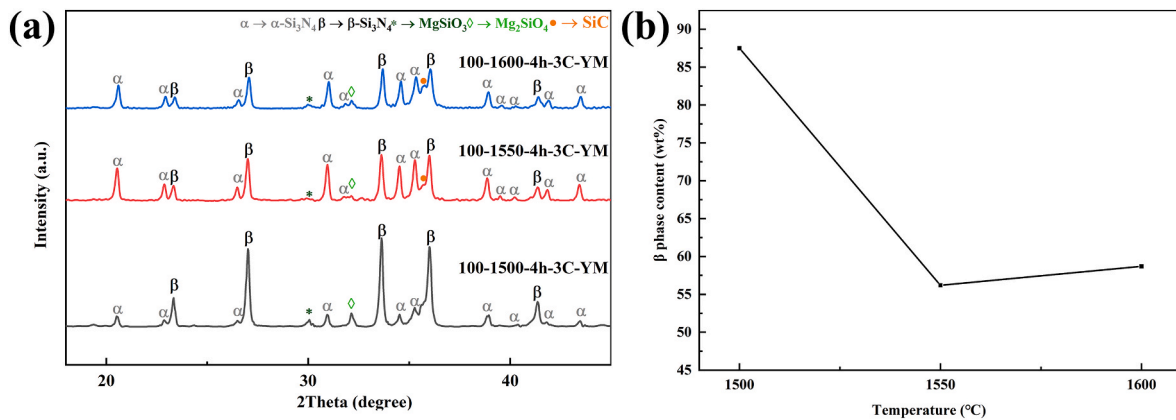


Fig. 10. The (a) XRD patterns and (b) line chart of  $\beta$  phase content variation with respect to temperature of  $\text{Si}_3\text{N}_4$  powder synthesized at different reaction temperatures.

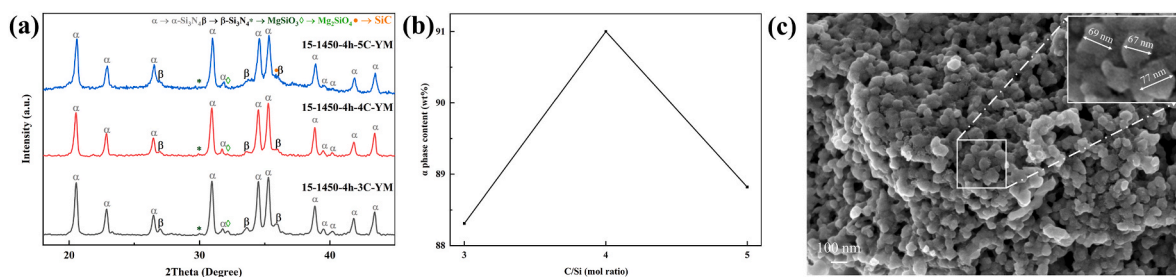


Fig. 11. The (a) XRD patterns of  $\text{Si}_3\text{N}_4$  powder synthesized with different C/Si mol ratios; (b) line chart of  $\alpha$  phase content variation with respect to C/Si mol ratio; (c) SEM image of  $\text{Si}_3\text{N}_4$  powder labeled 15-1450-4h-4C-YM.

demonstrating that the carbon addition facilitated high purity  $\alpha\text{-Si}_3\text{N}_4$  powder synthesis. The SEM image of the  $\alpha\text{-Si}_3\text{N}_4$  could be observed in Fig. 11 (c), and it showed uniform spherical particles similar to those in Fig. 6 (a). In addition, due to the low temperature of CRN process, particle size was extremely small at approximately 70 nm, suggesting nano-spherical  $\alpha\text{-Si}_3\text{N}_4$  powder could be synthesized by reducing the temperature of CRN with adding sintering aids. However, excessive carbon led to formation of SiC as a by-product and decreased  $\alpha$  phase content of  $\text{Si}_3\text{N}_4$  (Equation (11)), according to the results of  $\text{Si}_3\text{N}_4$  with C/Si ratio of 5 [32]. Therefore, a C/Si molar ratio of 4 was more suitable for synthesizing high purity  $\alpha\text{-Si}_3\text{N}_4$  powder.



### 3.4. Influence of sintering aids

The sample labeled 15-1450-4h-3C, 15-1450-4h-3C-YM, 15-1450-4h-4C, and 15-1450-4h-4C-YM were used for investigating the influence of sintering aids on the synthesis of  $\text{Si}_3\text{N}_4$  powder. The XRD patterns of the samples were shown in Fig. 12 (a). It was evident that the intensity of all peaks of  $\text{Si}_3\text{N}_4$  with added sintering aids (15-1450-3C-YM and 15-1450-4C-YM) was higher than that of  $\text{Si}_3\text{N}_4$  without added sintering aids (15-1450-3C and 15-1450-4C). In particular, a distinct broad peak was observed in sample 15-1450-4C but not in sample 15-1450-4C-YM, indicating incomplete reaction without the addition of sintering aids. Additionally, peaks corresponding to  $\text{MgSiO}_3$  and  $\text{Mg}_2\text{SiO}_4$  were detected in the sample with sintering aids, demonstrating that the liquid phase formed by MgO and  $\text{SiO}_2$  could accelerate solute transfer rate and promote the synthesis of  $\text{Si}_3\text{N}_4$  powder [41]. Therefore, the addition of sintering aids was beneficial for synthesizing  $\alpha\text{-Si}_3\text{N}_4$  powder at low temperature.

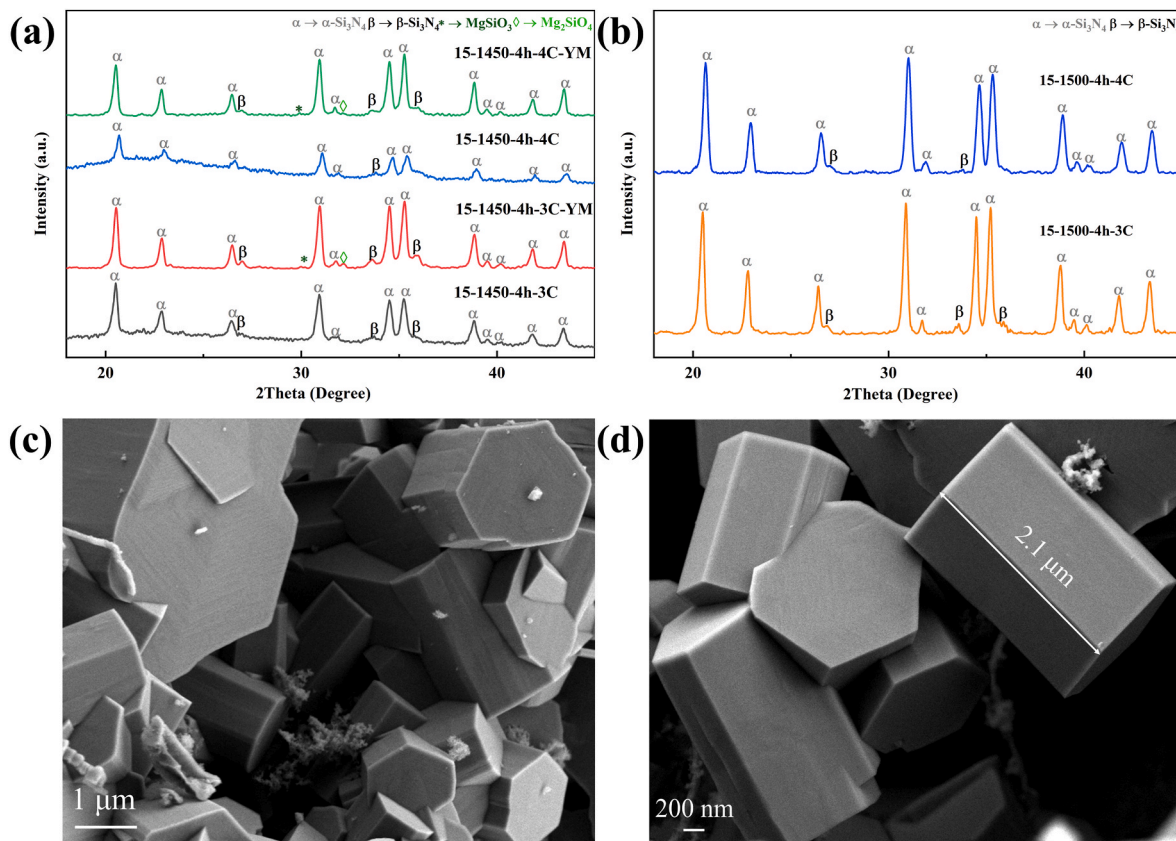
However, it should be noted that the presence of a certain amount of liquid phase also promoted the phase transformation of  $\text{Si}_3\text{N}_4$  which hindered achieving high purity  $\alpha\text{-Si}_3\text{N}_4$ . To address this issue, gradual increase in temperature was employed instead of adding sintering aids. Therefore,  $\text{Si}_3\text{N}_4$  powder labeled as 15-1500-4h-3C and 15-1500-4h-4C were synthesized for investigation, the XRD patterns were presented in Fig. 12 (b). Only characteristic peaks corresponding to  $\text{Si}_3\text{N}_4$  were observed, indicating the successful synthesis of high purity  $\text{Si}_3\text{N}_4$  powder. In fact, when the C/Si ratio was 4, the  $\alpha$  phase content reached up to 96 wt%, illustrating the successful synthesis of high purity  $\alpha\text{-Si}_3\text{N}_4$  powder using this process. The SEM image of the high purity  $\alpha\text{-Si}_3\text{N}_4$  powder was shown in Fig. 12 (c) and 12 (d), which indicated that the cross profile of the grain was regular hexagon and the grain length was approximately about 2  $\mu\text{m}$ . This demonstrated that the hexagonal prismatic  $\alpha\text{-Si}_3\text{N}_4$  crystal could be synthesized without adding sintering aids.

### 4. Conclusions

In this study,  $\text{Si}_3\text{N}_4$  powder with controllable  $\alpha$  and  $\beta$  phase content was synthesized using TEOS, glucose,  $\text{MgCl}_2$ , and  $\text{YCl}_3 \cdot 6\text{H}_2\text{O}$  as raw materials by sol-gel assisted CRN process. The research also investigated various factors on the phase transformation of  $\text{Si}_3\text{N}_4$ , including the  $\text{H}_2\text{O}/\text{TEOS}$  ratio, the temperature of CRN, the C/Si ratio, and sintering aids. The experimental findings could be summarized as follows.

- (1) The  $\alpha$  and  $\beta$  phase contents of  $\text{Si}_3\text{N}_4$  were significantly influenced by the  $\text{H}_2\text{O}/\text{TEOS}$  mol ratio in the sol. Increasing  $\text{H}_2\text{O}$  content greatly promoted the phase transformation of  $\text{Si}_3\text{N}_4$  when the  $\text{H}_2\text{O}/\text{TEOS}$  ratio was below 100. However, excessive  $\text{H}_2\text{O}$  content restricted the phase transformation due to the severe agglomeration of  $\text{SiO}_2$  caused by overhigh  $\text{H}_2\text{O}/\text{TEOS}$  ratio. The  $\beta\text{-Si}_3\text{N}_4$  powder with  $\beta$  phase content reached nearly 88 wt% could be synthesized at 1500 °C for 4 h by using the  $\text{H}_2\text{O}/\text{TEOS}$  ratio of





**Fig. 12.** (A) XRD patterns of Si<sub>3</sub>N<sub>4</sub> powder synthesized with or without added sintering aids; (b) XRD patterns of Si<sub>3</sub>N<sub>4</sub> powder synthesized at 1500 °C for 4 h without added sintering aids; (c) and (d) SEM images of the high purity α-Si<sub>3</sub>N<sub>4</sub> labeled 15-1500-4h-4C.

100 and the C/Si ratio of 3. The morphology of the β-Si<sub>3</sub>N<sub>4</sub> mainly consisted of rod-like whiskers with a length of approximately 1.4 μm.

- (2) By utilizing YCl<sub>3</sub>·6H<sub>2</sub>O and MgCl<sub>2</sub> as sintering aids along with the H<sub>2</sub>O/TEOS ratio of 15 and the C/Si ratio of 4 at a reaction temperature of 1450 °C for 4 h, α-Si<sub>3</sub>N<sub>4</sub> nano-powder with an α-phase content reaching up to 91 wt% could be synthesized. The powder exhibited uniform spherical particle with an average particle size around 70 nm.
- (3) The water-soluble sintering aid MgCl<sub>2</sub> could form eutectic liquid phase with SiO<sub>2</sub> during the process. This could not only promote the phase transformation of α-Si<sub>3</sub>N<sub>4</sub>, but also reduce the synthesis temperature of CRN process. Without adding any sintering aids or Si<sub>3</sub>N<sub>4</sub> seeds, high purity α-Si<sub>3</sub>N<sub>4</sub> with an α content reaching 96 wt % could be prepared at 1500 °C for 4 h by using the H<sub>2</sub>O/TEOS ratio of 15 and the C/Si ratio of 4. The morphology of α-Si<sub>3</sub>N<sub>4</sub> exhibited extremely regular hexagonal prism shape, and grain length was approximately 2 μm.

#### CRediT authorship contribution statement

**Yan Wang:** Conceptualization, Writing – original draft. **Zeyu Wang:** Data curation. **Zeping Zhu:** Formal analysis. **Jiaqi Wang:** Supervision. **Ziyang Meng:** Data curation. **Deqiang Wang:** Conceptualization, Writing – review & editing.

#### Declaration of competing interest

The authors declare that they have no known competing financial interests or personal relationships that could have appeared to influence the work reported in this paper.

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#### Appendix A. Supplementary data

Supplementary data to this article can be found online at <https://doi.org/10.1016/j.ceramint.2024.06.234>.

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